Process Research in Thin Film and Coating Technology

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Message from the Guest Editors

This Special Issue is dedicated to "Process Research in Thin Film and Coating Technology". The aim is to bring together scientists working on the technology of membranes and coatings from several disciplines to further develop new methods and ideas.

The topics to be covered include (but are not limited to):

- Polymers, metals, alloys, and composites for membranes and coatings;
- Novel materials for membranes and coatings;
- Synthesis and characterization of membranes and coatings;
- Industrial processes;
- Thermodynamics and transport properties;
- Theory and simulations;
- Applications.

Special Issue

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Message from the Editor-in-Chief

Processes (ISSN 2227-9717) provides an advanced forum for process/system-related research in chemistry, biology, material, energy, environment, food, pharmaceutical, manufacturing and allied engineering fields. The journal publishes regular research papers, communications, letters, short notes and reviews. Our aim is to encourage researchers to publish their experimental, theoretical and computational results in as much detail as necessary. There is no restriction on paper length or number of figures and tables.

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